## SUPPORT INFORMATION

## A self-curing triphenol A-based phthalonitrile resin precursor acts as

## flexibilizer and curing agent for phthalonitrile resin

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Table 1S. The reactions conditions for preparing TPPA-Ph precursors.

Figure 1S. LC-MS of TPPA-Ph precursor and molecular ion peaks in negative mode of products.

**Figure 2S.** Conversion α as a function of temperature for TPPA-Ph (P4) at various heating rates.

Figure 3S. Starink plots at various degrees of conversion for TPPA-Ph (P4).

Figure 4S. Variation of *E*α versus α for TPPA-Ph (P4) (Starink method).

Scheme 1S. Synthesis of resorcinol-based phthalonitrile resin precursor (DPPH).

Figure 58. <sup>1</sup>H NMR spectrum of DPPH.

**Table 1S.** The reactions conditions for preparing TPPA-Ph precursors.

	TPPA-Ph	The molar ratio of	Reaction	Reaction time
_	precursors	TPPA : $K_2CO_3$ : NPh	temperature (°C)	(h)
_	P1	1:2.5:3.2	80	24
	P2	1:1.5:3.1	25	24
	P3	1:1.5:2.05	25	24
	P4	1:1.5:1.05	25	24



Figure 1S. LC-MS of TPPA-Ph (P2) and molecular ion peaks in negative mode of products.



Figure 2S. Conversion α as a function of temperature for TPPA-Ph (P4) at various heating rates.



Figure 38. Starink plots at various degrees of conversion for TPPA-Ph (P4).



Figure 4S. Variation of *E*α versus α for TPPA-Ph (P4) (Starink method).



Scheme 1S. Synthesis of resorcinol-based phthalonitrile resin precursor (DPPH).



Figure 5S. <sup>1</sup>H NMR spectrum of DPPH.